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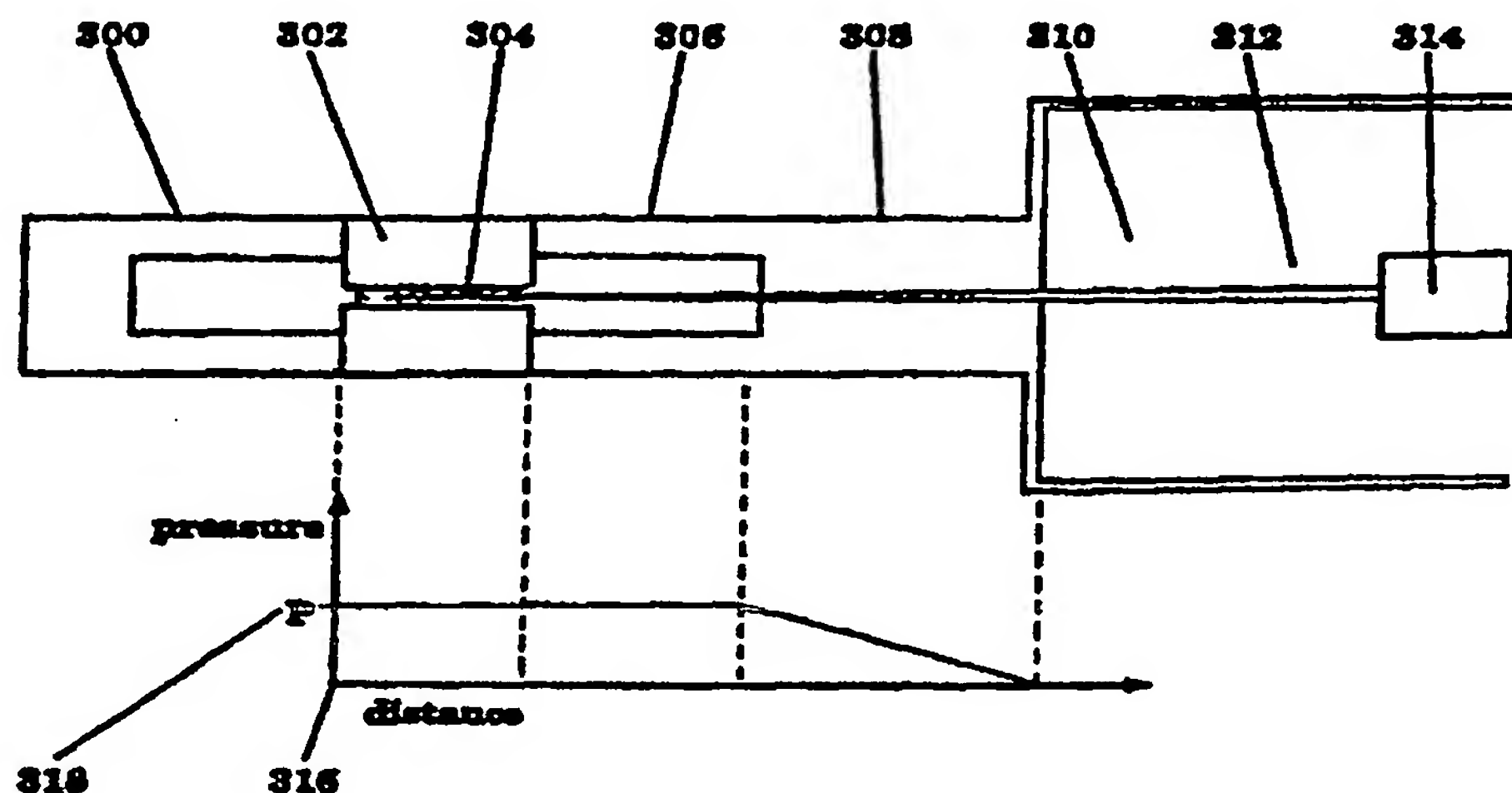
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(54) Title: DISCHARGE LAMP SOURCES APPARATUS AND METHODS

**Experimental arrangement for obtaining spectral data**

## (57) Abstract

A capillary discharge extreme ultraviolet lamp source apparatus and method for extreme ultraviolet microlithography. The capillary source includes a lamp body (306); a bore having electrodes (300), insulators (302) and a discharge plasma region (304).

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